

Brice Gautier

List of Publications by Year in descending order

Source: <https://exaly.com/author-pdf/2732801/publications.pdf>

Version: 2024-02-01

82
papers

1,103
citations

393982

19
h-index

454577

30
g-index

82
all docs

82
docs citations

82
times ranked

1528
citing authors

| # | ARTICLE | IF | CITATIONS |
|----|--|-----|-----------|
| 1 | Mechanical Switching of Ferroelectric Domains in 33â€200 nmâ€Thick Solâ€Gelâ€Grown PbZr_{0.2}Ti_{0.8}O₃ Films Assisted by Nanocavities. Advanced Electronic Materials, 2022, 8, . | 2.6 | 4 |
| 2 | Ionic migrations during poling process in lanthanum aluminate investigated by time of flight-secondary ions mass spectrometry and piezoresponse force microscopy combined methodology. Journal of Vacuum Science and Technology B:Nanotechnology and Microelectronics, 2020, 38, 034002. | 0.6 | 0 |
| 3 | Characterizing Ferroelectricity with an Atomic Force Microscopy: An All-Around Technique. Nanoscience and Technology, 2019, , 173-203. | 1.5 | 1 |
| 4 | Combined ToF-SIMS and AFM protocol for accurate 3D chemical analysis and data visualization. Journal of Vacuum Science and Technology B:Nanotechnology and Microelectronics, 2018, 36, . | 0.6 | 5 |
| 5 | Accurate Measurement at the Nanoscale of Remnant Polarisation Charge in Ferroelectric Films. , 2018, , . | | 0 |
| 6 | Iterative deconvolution using the MRI model for removing experimental broadening and shift effects in SIMS depth profiles. Surface and Interface Analysis, 2018, 50, 1336-1342. | 0.8 | 2 |
| 7 | Effect of LiNbO₃ polarity on the structural, optical and acoustic properties of epitaxial ZnO and Mg_xZn_{1â€x}O films. Journal Physics D: Applied Physics, 2018, 51, 484003. | 1.3 | 3 |
| 8 | Quantitative and simultaneous analysis of the polarity of polycrystalline ZnO seed layers and related nanowires grown by wet chemical deposition. Nanotechnology, 2017, 28, 095704. | 1.3 | 11 |
| 9 | A new technique based on current measurement for nanoscale ferroelectricity assessment: Nano-positive up negative down. Review of Scientific Instruments, 2017, 88, 023901. | 0.6 | 28 |
| 10 | Investigation of tip-depletion-induced fail in scanning capacitance microscopy for the determination of carrier type. Ultramicroscopy, 2017, 174, 46-49. | 0.8 | 5 |
| 11 | Electrical properties of Molecular Beam Epitaxy grown Barium Titanate probed by conductive Atomic Force Microscopy. Thin Solid Films, 2017, 642, 324-327. | 0.8 | 0 |
| 12 | Interpretation of multiscale characterization techniques to assess ferroelectricity: The case of GaFeO3. Ultramicroscopy, 2017, 172, 47-51. | 0.8 | 12 |
| 13 | Geometric conductive filament confinement by nanotips for resistive switching of HfO2-RRAM devices with high performance. Scientific Reports, 2016, 6, 25757. | 1.6 | 62 |
| 14 | Surface atomic and chemical structure of relaxor Sr0.63Ba0.37Nb2O6(001). Applied Physics Letters, 2015, 106, 242901. | 1.5 | 3 |
| 15 | Study and characterization of the irreversible transformation of electrically stressed planar Ti/TiOx/Ti junctions. Journal of Applied Physics, 2015, 118, 144502. | 1.1 | 0 |
| 16 | Nanoscale study of perovskite BiFeO3/spinel (Fe,Zn)3O4 co-deposited thin film by electrical scanning probe methods. Applied Surface Science, 2015, 351, 531-536. | 3.1 | 7 |
| 17 | Structural study and ferroelectricity of epitaxial BaTiO3 films on silicon grown by molecular beam epitaxy. Journal of Applied Physics, 2014, 116, . | 1.1 | 20 |
| 18 | Spurious phenomena occurring during current measurement on ultra-thin dielectric layers: From electro-thermal effects to surface damage. Journal of Applied Physics, 2014, 115, 134103. | 1.1 | 3 |

| # | ARTICLE | IF | CITATIONS |
|----|---|-----|-----------|
| 19 | Phase transitions in [001]-oriented morphotropic PbZr _{0.52} Ti _{0.48} O ₃ thin film deposited onto SrTiO ₃ -buffered Si substrate. Journal of Applied Physics, 2014, 115, . | 1.1 | 12 |
| 20 | Electromechanical response of amorphous LaAlO ₃ thin film probed by scanning probe microscopies. Applied Physics Letters, 2014, 105, . | 1.5 | 25 |
| 21 | Imaging by atomic force microscopy of the properties difference of the layers covering the facets created during SIMS analysis. Applied Surface Science, 2014, 308, 24-30. | 3.1 | 0 |
| 22 | Phase transition in ferroelectric Pb(Zr _{0.52} Ti _{0.48})O ₃ epitaxial thin films. Thin Solid Films, 2014, 553, 85-88. | 0.8 | 5 |
| 23 | Epitaxial Growth of Ferroelectric Pb(Zr,Ti)O ₃ Layers on GaAs. Materials Research Society Symposia Proceedings, 2014, 1675, 93-98. | 0.1 | 1 |
| 24 | Chemistry and structure of BaTiO ₃ ultra-thin films grown by different O ₂ plasma power. Chemical Physics Letters, 2014, 592, 206-210. | 1.2 | 21 |
| 25 | Structural observation of piezoelectric inhomogeneity in a mixed-orientation Na _{0.5} Bi _{0.5} TiO ₃ perovskite thin film. Applied Physics Letters, 2014, 105, . | 1.5 | 7 |
| 26 | Epitaxial inversion on ferromagnetic (Fe,Zn) ₃ O ₄ /ferroelectric BiFeO ₃ core-shell nanodot arrays using three dimensional nano-seeding assembly. Journal of Applied Physics, 2013, 113, . | 1.1 | 12 |
| 27 | SIMS quantification of thick Si _{1-x} Gex films (0 ≤ x ≤ 1) using the isotopic comparative method under Ar+ beam. Surface and Interface Analysis, 2013, 45, 376-380. | 0.8 | 4 |
| 28 | Ferroelectric Pb(Zr,Ti)O ₃ epitaxial layers on GaAs. Applied Physics Letters, 2013, 103, . | 1.5 | 23 |
| 29 | Room temperature multiferroicity in Ga _{0.6} Fe _{1.4} O ₃ :Mg thin films. Journal of Applied Physics, 2013, 113, . | 1.1 | 32 |
| 30 | Electrical properties of (110) epitaxial lead-free ferroelectric Na _{0.5} Bi _{0.5} TiO ₃ thin films grown by pulsed laser deposition: Macroscopic and nanoscale data. Journal of Applied Physics, 2012, 111, . | 1.1 | 46 |
| 31 | IMPACT OF THE AMBIENT HUMIDITY ON THE KINETICS OF FORMATION OF FERROELECTRIC DOMAINS IN MONOCRYSTALLINE LiTaO ₃ . International Journal of Nanoscience, 2012, 11, 1240013. | 0.4 | 2 |
| 32 | Strain effect in PbTiO ₃ /PbZr _{0.2} Ti _{0.8} O ₃ superlattices: From polydomain to monodomain structures. Journal of Applied Physics, 2012, 112, . | 1.1 | 7 |
| 33 | Chemistry and Atomic Distortion at the Surface of an Epitaxial BaTiO ₃ Thin Film after Dissociative Adsorption of Water. Journal of Physical Chemistry C, 2012, 116, 21802-21809. | 1.5 | 60 |
| 34 | KTa _{0.65} Nb _{0.35} O ₃ thin films epitaxially grown by pulsed laser deposition on metallic and oxide epitaxial electrodes. Applied Surface Science, 2012, 258, 9297-9301. | 3.1 | 5 |
| 35 | Single crystal PZT thin film membrane with highly conductive electrodes. , 2012, , . | | 0 |
| 36 | Pulsed laser deposition of epitaxial ferroelectric Pb(Zr,Ti)O ₃ films on silicon substrates. Thin Solid Films, 2012, 520, 4604-4607. | 0.8 | 12 |

| # | ARTICLE | IF | CITATIONS |
|----|---|-----|-----------|
| 37 | Molecular beam epitaxy growth of BaTiO ₃ thin films and crucial impact of oxygen content conditions on the electrical characteristics. Thin Solid Films, 2012, 520, 4595-4599. | 0.8 | 27 |
| 38 | Epitaxial growth and electrical measurement of single crystalline Pb(Zr _{0.52} Ti _{0.48})O ₃ thin film on Si(001) for micro-electromechanical systems. Thin Solid Films, 2012, 520, 4572-4575. | 0.8 | 32 |
| 39 | Integration of functional oxides on silicon for novel devices. , 2011, , . | | 0 |
| 40 | Influence of the surrounding ambient on the reliability of the electrical characterization of thin oxide layers using an atomic force microscope. Microelectronics Reliability, 2011, 51, 2097-2101. | 0.9 | 4 |
| 41 | The isotopic comparative method (ICM) for SIMS quantification of boron in silicon up to 40 at.%. Surface and Interface Analysis, 2011, 43, 36-40. | 0.8 | 5 |
| 42 | Isotopic comparative method (ICM) for the determination of variations of the ion yields in boron-doped silicon as a function of oxygen concentration in the 0-10 at.% range. Surface and Interface Analysis, 2011, 43, 137-140. | 0.8 | 3 |
| 43 | Epitaxy of BaTiO ₃ thin film on Si(001) using a SrTiO ₃ buffer layer for non-volatile memory application. Microelectronic Engineering, 2011, 88, 1232-1235. | 1.1 | 99 |
| 44 | Ferroelectricity in a quasicrystalline ultrathin BaTiO ₃ film. Physical Review B, 2011, 84, . | 1.1 | 17 |
| 45 | Toward a better understanding of the nanoscale degradation mechanisms of ultra-thin SiO ₂ /Si films: Investigation of the best experimental conditions with a conductive-atomic force microscope. Journal of Applied Physics, 2011, 110, . | 1.1 | 4 |
| 46 | Finite element method simulation of the domain growth kinetics in single-crystal LiTaO ₃ : Role of surface conductivity. Journal of Applied Physics, 2011, 110, 052016. | 1.1 | 24 |
| 47 | Study of the physical and electrical degradation of thin oxide films by atomic force microscope. Journal of Vacuum Science and Technology B: Nanotechnology and Microelectronics, 2011, 29, 01AA06. | 0.6 | 7 |
| 48 | Abnormal switching of ferroelectric domains created by the tip of an atomic force microscope in a congruent LiTaO ₃ single-crystal thin film. Journal of Applied Physics, 2011, 110, 024102. | 1.1 | 12 |
| 49 | Influence of the ferroelectric polarization on the electronic structure of BaTiO ₃ thin films. Surface and Interface Analysis, 2010, 42, 1690-1694. | 0.8 | 17 |
| 50 | Macroscopic and nanoscale electrical properties of pulsed laser deposited (100) epitaxial lead-free Na _{0.5} Bi _{0.5} TiO ₃ thin films. Journal of Applied Physics, 2010, 107, . | 1.1 | 43 |
| 51 | Low-temperature transition to a superconducting phase in boron-doped silicon films grown on (001)-oriented silicon wafers. Physical Review B, 2010, 81, . | 1.1 | 34 |
| 52 | The Superconducting Transition in Boron Doped Silicon Films. Acta Physica Polonica A, 2010, 118, 1026-1027. | 0.2 | 0 |
| 53 | Scaling Effects on Ferro-Electrics: Application in Nanoelectronics and Characterization. , 2009, , . | | 1 |
| 54 | Nanoscale Characterization Of Ultra-Thin Dielectrics Using Scanning Capacitance Microscopy. , 2009, , . | | 1 |

| # | ARTICLE | IF | CITATIONS |
|----|--|-----|-----------|
| 55 | Nanoscale leakage current measurements in metal organic chemical vapor deposition crystalline SrTiO ₃ films. Thin Solid Films, 2009, 517, 1868-1873. | 0.8 | 14 |
| 56 | Interpretation of scanning capacitance microscopy for thin oxides characterization. Thin Solid Films, 2009, 517, 6721-6725. | 0.8 | 6 |
| 57 | Nanoscale Study of the Influence of Atomic Oxygen on the Electrical Properties of LaAlO ₃ Thin High-k Oxide Films Deposited by Molecular Beam Epitaxy. , 2009, , . | | 2 |
| 58 | Quantitative SIMS measurement of high concentration of boron in silicon (up to 20at.%) using an isotopic comparative method. Applied Surface Science, 2008, 255, 1377-1380. | 3.1 | 19 |
| 59 | A new mechanicalâ€œelectrical approach to the wheel-rail contact. Wear, 2008, 265, 1408-1416. | 1.5 | 20 |
| 60 | Silicon nanoparticle formation by short pulse electrochemical etching in the transition regime. Journal of Applied Physics, 2006, 100, 104307. | 1.1 | 7 |
| 61 | Deconvolution of very low primary energy SIMS depth profiles. Applied Surface Science, 2006, 252, 6478-6481. | 3.1 | 13 |
| 62 | AFM study of the SIMS beam induced roughness in monocrystalline silicon in presence of initial surface or bulk defects of nanometric size. Applied Surface Science, 2006, 252, 6448-6451. | 3.1 | 5 |
| 63 | Surface roughening and erosion rate change at low energy SIMS depth profiling of silicon during oblique bombardment. Applied Surface Science, 2006, 253, 2662-2670. | 3.1 | 12 |
| 64 | Comparison of scanning capacitance microscopy measurements in open and closed loop modes on highly doped silicon monolayers. Solid-State Electronics, 2006, 50, 1479-1482. | 0.8 | 2 |
| 65 | Nanoscale observation of the distribution of the polarization orientation of ferroelectric domains in lithium niobate thin films. Thin Solid Films, 2006, 515, 1592-1596. | 0.8 | 17 |
| 66 | Impact of introducing CuSiN self-aligned barriers in advanced copper interconnects. Microelectronic Engineering, 2005, 82, 587-593. | 1.1 | 18 |
| 67 | Initial stages of silicon anodization in the transition regime: Nanoparticle formation. Applied Physics Letters, 2005, 86, 213107. | 1.5 | 7 |
| 68 | Growth and nanoscale ferroelectric investigation of radiofrequency-sputtered LiNbO ₃ thin films. Materials Chemistry and Physics, 2004, 86, 340-346. | 2.0 | 17 |
| 69 | Imaging by atomic force microscopy of the electrical properties difference of the facets of oxygen-ion-induced ripple topography in silicon. Applied Surface Science, 2004, 231-232, 136-140. | 3.1 | 15 |
| 70 | Influence of surface orientation on the formation of sputtering-induced ripple topography in silicon. Applied Surface Science, 2004, 231-232, 678-683. | 3.1 | 9 |
| 71 | Nanoscale study of the ferroelectric properties of SrBi ₂ Nb ₂ O ₉ thin films grown by pulsed laser deposition on epitaxial Pt electrodes using atomic force microscope. Applied Surface Science, 2003, 217, 108-117. | 3.1 | 25 |
| 72 | Nanoscale Investigation of the Ferroelectric Properties of Sol-Gel (PbZr x Ti 1âˆ’ x) O 3 Films. Ferroelectrics, 2002, 269, 219-224. | 0.3 | 5 |

| # | ARTICLE | IF | CITATIONS |
|----|---|-----|-----------|
| 73 | Influence of the Microstructure and of an Ion Beam Etching on the Domain Propagation in PZT Thin Films. <i>Integrated Ferroelectrics</i> , 2002, 50, 231-240. | 0.3 | 1 |
| 74 | Electrochemical behaviour of ceramic sol-gel coatings on mild steel. <i>Journal of Non-Crystalline Solids</i> , 2001, 293-295, 527-533. | 1.5 | 45 |
| 75 | High-resolution inspections of ferroelectric thin PZT films. <i>Annales De Chimie: Science Des Materiaux</i> , 2001, 26, 145-149. | 0.2 | 4 |
| 76 | Er deposition in the submonolayer range on weakly boron-doped Si(111) surface. <i>Journal of Vacuum Science and Technology A: Vacuum, Surfaces and Films</i> , 2000, 18, 2239. | 0.9 | 3 |
| 77 | Scanning tunneling microscopy study of the Er/Ge(111) c(2 $\sqrt{3}$ × $\sqrt{3}$) interface. <i>Journal of Vacuum Science and Technology A: Vacuum, Surfaces and Films</i> , 2000, 18, 2738-2741. | 0.9 | 2 |
| 78 | Two-dimensional epitaxial ErSi ₂ grown on B-passivated Si(111) $\sqrt{3}\sqrt{3}$ surfaces. <i>Physical Review B</i> , 1999, 60, 11645-11652. | 1.1 | 5 |
| 79 | SIMS depth profile correction for the study of the first step of the diffusion of boron in silicon. <i>Nuclear Instruments & Methods in Physics Research B</i> , 1998, 142, 361-376. | 0.6 | 8 |
| 80 | Toward a better reliability in the deconvolution of SIMS depth profiles. <i>Surface and Interface Analysis</i> , 1998, 26, 974-983. | 0.8 | 22 |
| 81 | Carbon self-organization in the ternary Si _{1-x-y} GexCy alloy. <i>Journal of Applied Physics</i> , 1998, 83, 5251-5257. | 1.1 | 2 |
| 82 | Quantification of germanium and boron in heterostructures Si/Si _{1-x} Gex/Si by SIMS. <i>Thin Solid Films</i> , 1997, 294, 54-58. | 0.8 | 28 |